1999-488932/41 A82 G02 (A14) (IZU- 1998.01.27 MIZUTANI PAINT MFG \*JP 11209622-A 1998.01.27 1998-014477(+1998JP-014477) (1999-08.03) C08L 83/10, B01J 13/00 // C01B 33/149

Aqueous dispersion useful for preparing coating materials consisting of colloidal silica coated with vinyl (co)polymer(s)
binding to silica surface with cationic polymerisation activator

residue, and aqueous medium C1999-143578

Aqueous dispersion (I) comprising (A) and (B) is claimed.

(A) = colloidal silica coated with vinyl (co)polymer(s) binding to silica surface with cationic polymerisation activator residue;

(B) = aqueous medium. Preparation of (I) comprising cationic (co)polymerisation of vinyl monomer(s) on silica surface in (B) is claimed, also.

USF

(I) is useful as material for the preparation of coating material (II) (claimed).

ADVANTAGE

(II) gives coating films having far improved antifouling properties

A(12-B1) G(2-A2C, 2-A3)



and weatherability. Gloss and mechanical properties of the coated film(s) are controlled readily by varying ratio of vinyl (co)polymer(s)/silica particles.

PREFERRED (A)

(A) is composed of 100 pts wt of (co)polymer(s) derived from one or more of (meth)acrylate monomer(s), aromatic vinyl monomer(s) or vinyl ester monomer(s), 3-500 pts wt of colloidal silica and cationic polymerisation activator(s) 0.1-20 pts wt.

**EMBODIMENT** 

Colloidal silica 1(0) pts wt is dispersed in (B) (preferably water), nonionic surfactant(s) and cationic polymerisation activator(s) 0.1-20 (opt. 1-10) pts wt are added. Monomer(s) to form (co)polymer layer is added to the above dispersion dropwise to become vinyl monomer(s) 100 pts wt and colloidal silica particles 3-500 (pref. 10-310, opt. 20-200) pts wt to obtain (I).

**EXAMPLE** 

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added dropwise to a composition of 50 % colloidal silica 200 g, nonionic surfactant 3 g, 2,2'-azobisamidinopropane dihydrochloride  2.0 g and distilled water 100 g at ordinary temperature. The vinyl monomer composition mentioned above 95g was added to the
A vinyl monomer composition consisting of methyl methacrylate/n-butyl acrylate/methacrylic acid= 49/5/1(w/w) 5 g was